

```

FILE 'REGISTRY' ENTERED AT 07:24:05 ON 11 MAR 2005
  E NITROUS OXIDE/CN
L1      1 SEA ABB=ON  PLU=ON  "NITROUS OXIDE"/CN

FILE 'HCAPLUS' ENTERED AT 07:24:51 ON 11 MAR 2005
L2      38622 SEA ABB=ON  PLU=ON  L1 OR N2O OR NITROUS OXIDE OR DINITROGEN
      OXIDE OR DINITROGEN MONOOXIDE

FILE 'REGISTRY' ENTERED AT 07:24:59 ON 11 MAR 2005
  E RESISTS/CN

FILE 'HCAPLUS' ENTERED AT 07:25:00 ON 11 MAR 2005
  E RESISTS/CT
  E E3+ALL/CT
L3      71404 SEA ABB=ON  PLU=ON  RESISTS/CT OR (MASKING/CT OR MASKS/CT OR
      "ELECTRON BEAM RESISTS"/CT OR "RESISTS (L) ELECTRON-BEAM,
      NEG.-WORKING"/CT OR "RESISTS (L) ELECTRON-BEAM, POS.-WORKING"/C
      T OR "ION BEAM RESISTS"/CT OR PHOTORESISTS/CT OR "NEGATIVE
      PHOTORESISTS"/CT OR "POSITIVE PHOTORESISTS"/CT) OR ("SOLDER
      RESISTS"/CT OR "RESISTS (L) PHOTO-, SOLDER"/CT OR "X-RAY
      RESISTS"/CT) OR "PHOTOMASKS (LITHOGRAPHIC MASKS)"/CT OR
      PHOTORESIST##### OR (MASK#### OR RESIST##) (2A)PHOTO##### OR
      PHOTOMASK#####
      E ORGANOSIL/CT
      E E3+ALL/CT
      E E5+ALL/CT
      S C/ELS AND GLASS

FILE 'REGISTRY' ENTERED AT 07:27:22 ON 11 MAR 2005

FILE 'HCAPLUS' ENTERED AT 07:27:27 ON 11 MAR 2005

FILE 'REGISTRY' ENTERED AT 07:27:53 ON 11 MAR 2005
L4      1 SEA ABB=ON  PLU=ON  C/ELS AND SI/ELS AND O/ELS AND GLASS
      D IDE
L5      4 SEA ABB=ON  PLU=ON  C/ELS AND GLASS
L6      622635 SEA ABB=ON  PLU=ON  C/ELS AND O/ELS AND SI/ELS
L7      3892 SEA ABB=ON  PLU=ON  SILICATE AND L6

FILE 'HCAPLUS' ENTERED AT 07:29:46 ON 11 MAR 2005
L8      2121 SEA ABB=ON  PLU=ON  L7(L) (GLASS OR OSG)
L9      182 SEA ABB=ON  PLU=ON  OSG OR ORGANOSILICAT####(4A)GLASS###
L10     120 SEA ABB=ON  PLU=ON  OSG OR ORGANIC SILICAT####(4A)GLASS###
L11     16 SEA ABB=ON  PLU=ON  L7(L) SOG
L12     122 SEA ABB=ON  PLU=ON  L7(L) (SPUN OR SPUNON OR SPINON OR SPIN)
L13     90241 SEA ABB=ON  PLU=ON  ((L4 OR L5) OR L7)
L14     63201 SEA ABB=ON  PLU=ON  (L4 OR L5) OR (L8 OR L9 OR L10 OR L11 OR
      L12)
      E GLASSES/CT
      E GLASS/CT
L15     1043 SEA ABB=ON  PLU=ON  GLASS(L) (ORGANOSILIC##### OR ORGANIC
      SILICA#### OR ORGANOSILICA####)
L16     64054 SEA ABB=ON  PLU=ON  (L8 OR L9 OR L10 OR L11 OR L12) OR L15 OR
      (L4 OR L5)
L17     3270 SEA ABB=ON  PLU=ON  (L8 OR L9 OR L10 OR L11 OR L12) OR L15 OR
      L4
L18     77 SEA ABB=ON  PLU=ON  L3 AND L17
L19     3 SEA ABB=ON  PLU=ON  L2 AND L18
      D ALL HITSTR TOT
L20     27 SEA ABB=ON  PLU=ON  L2 AND L3 AND (L8 OR L9 OR L10 OR L11 OR
      L12 OR L13 OR L14 OR L15 OR L16 OR L17 OR L18)
L21     24 SEA ABB=ON  PLU=ON  L20 NOT L19
L22     10 SEA ABB=ON  PLU=ON  L21 AND (STRIP##### OR REMOV##### OR
      ETCH##### OR ATTACK#### OR DECOMPOS##### OR SACRIFIC####) (4A)
      (PHOTORESIST##### OR RESIST)
      D BIB AB HITSTR TOT
      D L22 ALL HITSTR TOT
L23     1 SEA ABB=ON  PLU=ON  (L9 OR L10 OR L11 OR L12) AND L2 AND L3

```

```

      D ALL HITSTR
L24   2121 SEA ABB=ON  PLU=ON  L7(L)GLASS
L25   2 SEA ABB=ON  PLU=ON  L24 AND L2 AND L3
L26   2 SEA ABB=ON  PLU=ON  L25 NOT L23
      D ALL HITSTR TOT
      E RESISTS/CT
      E E3+ALL/CT
L27   5422 SEA ABB=ON  PLU=ON  (RESISTS/CT OR MASKING/CT OR MASKS/CT OR
      "ELECTRON BEAM RESISTS"/CT OR "RESISTS (L) ELECTRON-BEAM,
      NEG.-WORKING"/CT OR "RESISTS (L) ELECTRON-BEAM, POS.-WORKING"/C
      T OR "ION BEAM RESISTS"/CT OR PHOTORESISTS/CT OR "NEGATIVE
      PHOTORESISTS"/CT OR "POSITIVE PHOTORESISTS"/CT OR "RESISTS (L)
      PHOTO-, UV, POS.-WORKING"/CT OR "RESISTS (L) PHOTO-, UV"/CT OR
      "RESISTS (L) PHOTO-, DRY-FILM"/CT OR "RESISTS (L) PHOTO-,
      NEG.-WORKING"/CT OR "RESISTS (L) PHOTO-, POS.-WORKING"/CT OR
      "RESISTS (L) PHOTO-, SOLDER"/CT OR "SOLDER RESISTS"/CT OR
      "RESISTS (L) PHOTO-, SOLDER"/CT OR "X-RAY RESISTS"/CT) (L) (REMOV
      ##### OR SACRIFIC##### OR ETCH##### OR STRIP OR STRIPP####)
L28   43 SEA ABB=ON  PLU=ON  L2 AND L27
L29   4 SEA ABB=ON  PLU=ON  (OSG OR GLASS OR ORGANOSILIC##### OR
      ORGANO SILIC##### OR ORGANIC SILIC####) AND L28
      D ALL HITSTR TOT
L30   265 SEA ABB=ON  PLU=ON  (L11 OR L12) OR (L18 OR L19 OR L20 OR L21
      OR L22 OR L23) OR (L25 OR L26) OR (L28 OR L29)
L31   SEL PLU=ON  L30 1- PRN :      226 TERMS

FILE 'WPIX, JAPIO' ENTERED AT 07:44:56 ON 11 MAR 2005
L32   290 SEA ABB=ON  PLU=ON  L31
L33   33 SEA ABB=ON  PLU=ON  L32 AND (STRIP##### OR REMOV##### OR
      SACRIFIC#####) (3A) (RESIST OR PHOTORESIST)
L34   13 SEA ABB=ON  PLU=ON  L33 AND (NITROUS OR N2O OR DINITROGEN
      OXIDE OR DINITROGEN MONOOXIDE)
      D MAX 1-13
L35   4 SEA ABB=ON  PLU=ON  L34 AND (OSG OR GLASS#### OR ORGANOSIL#####
      ## OR SOG)
      D MAX 1-4

FILE 'JICST-EPLUS' ENTERED AT 07:48:38 ON 11 MAR 2005
L36   154 SEA ABB=ON  PLU=ON  (STRIP##### OR REMOV##### OR SACRIFIC#####
      #) (3A) (RESIST OR PHOTORESIST)
L37   15 SEA ABB=ON  PLU=ON  L36 AND (OSG OR GLASS#### OR ORGANOSIL#####
      ## OR SOG)
L38   1 SEA ABB=ON  PLU=ON  L36 AND (NITROUS OR N2O OR DINITROGEN
      OXIDE OR DINITROGEN MONOOXIDE)
L39   0 SEA ABB=ON  PLU=ON  L37 AND L38
      D L38 ALL

FILE 'HCAPLUS' ENTERED AT 07:49:48 ON 11 MAR 2005
L40   937 SEA ABB=ON  PLU=ON  ASH####(3A) (RESIST OR PHOTORESIST)
L41   235 SEA ABB=ON  PLU=ON  ((L7 OR L8 OR L9 OR L10 OR L11 OR L12) OR
      L15 OR (L17 OR L18 OR L19 OR L20 OR L21 OR L22 OR L23 OR L24
      OR L25 OR L26 OR L27 OR L28 OR L29 OR L30)) AND L40
L42   1 SEA ABB=ON  PLU=ON  L41 AND (L1 OR NITROUS OR N2O OR DINITROGEN
      OXIDE OR DINITROGEN MONOOXIDE)
      D ALL HITSTR

FILE 'SCISEARCH' ENTERED AT 07:52:05 ON 11 MAR 2005
      E OLNNESS G, 1990/RE
L43   1 SEA ABB=ON  PLU=ON  "OLNNESS G, 1993, V315, P261, P MRS S"/RE
      D ALL

```